

Optimized semiconductor single electron pumps for metrology and quantum technology

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Since the 2019 revision of the SI systems of units the international units are defined by fixed numerical values of a set of natural constants. With respect to electricity, the base unit of the electrical current, the Ampere, is defined by the value of the electrical charge of the electron of $e = 1.602\,176\,634 \times 10^{-19}$ As.

As a consequence, a primary quantum standard for the Ampere can be realized using so-called single electron pumps (SEPs) [1]. These are based on single electron transistors that are driven by an oscillating gate voltage with frequency f . During one oscillation cycle one electron is captured from source and later ejected to drain thereby generating a quantized current $I = ef$ only given by the applied frequency and the defined value e .

So far, the best demonstrated quantization accuracy of such an SEP has been obtained in gated quantum dots in a GaAs/AlGaAs heterostructures where a quantised current of about 100 pA has been found equal to ef within an uncertainty of 1.6×10^{-7} [2]. This extreme accuracy is not only relevant for metrology but also for spin qubits, where the clocked transport of electrons is discussed as a quantum link between neighbouring qubits [3].

In the talk I will first summarize the state of quantum current metrology based on single electron pumps. Then, I will discuss an optimized gate designs and a reliable

fabrication process for these devices [4] and will show how single- and double gate operation during pumping allows to shift the single electron capturing process from the so-called back-tunneling (or decay cascade) regime to the thermal regime where the capturing error is determined by the fermi distribution of the source [5].

References

- [1] H. Scherer, Hans W. Schumacher *Ann. Phys.* 531 (2019) 1800371.
- [2] F. Stein et al., *Appl. Phys. Lett.* 107 (2015) 103501.
- [3] A.M.J Zwerver et al., *PRX Quantum* 4 (2023) 030303.
- [4] T. Gerster et al., in preparation.
- [5] F. Hohls, et al., *Phys. Rev. B* 105 (2022) 205425.

Figures

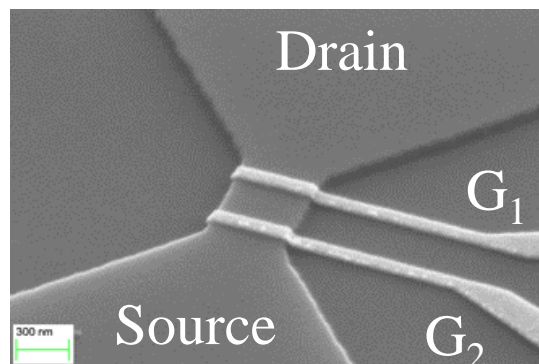


Figure 1: Single electron pump fabricated from an etched GaAs/AlGaAs heterostructure with top gates G defining a single electron transistor between source and drain. Operating the device with oscillating gate voltages with frequency f allows the generation of quantized currents $I = ef$ from source to drain.